

Klaus Haft

Partner at Hoyng Rokh Monégier LLP in Düsseldorf, Germany



Klaus Haft obtained his physics degree in 1997, became an attorney in 2002, and advises on patent infringement litigation cases, subsequent litigation regarding damages as well as licenses in the entire area of intellectual property law, particularly in the fields of patents. His particular focus is on standards, electronics, software, optics, electrics and general mechanics.

Klaus studied in Würzburg and Munich. He completed his degree thesis in 1997 as a member of the Spin Muon Collaboration at the European Center for Particle Physics, CERN, in Geneva, Switzerland. Parallel to his studies, he started in 1990 to specialize in intellectual property law and, in particular, in patent law.

Klaus is a visiting lecturer at the Maastricht University, Vice-President of the European Patent Lawyers Association (EPLAW) and Secretary of the Licensing Executives Society (LES) Germany.

Representative matters

- Since 2013, ongoing advice and representation in numerous matters relating to telecoms and standards for a global market leader.
- Since 2008, ongoing advice and representation in numerous matters for a large consumer electronics company
- Since 2010, ongoing advice and representation in numerous matters for a leading optics company
- Since 2011, ongoing advice and representation in numerous matters for a leading chipset manufacturer

Education

- Higher Regional Court Munich (Law, 2002)
- Universities of Würzburg and Munich (Law, 2000)
- Diploma in Physics at the European Center for Particle Physics, CERN (1997)